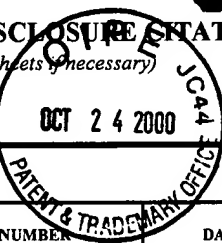


INFORMATION DISCLOSURE CITATION

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Docket Number (Optional)

13521(ARC920000067U)

Application Number

09/634,171

Applicant(s)

Emmanuel I. Cooper et al.

Filing Date

August 9, 2000

Group Art Unit

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
JST		2,654,703	10/06/53	Brown			
JST		4,014,759	03/29/77	McMullen et al.			
JST		4,053,373	10/11/77	McMullen et al.			
JST		4,208,254	06/17/80	Mitsumoto et al.			
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JST		5,587,026	12/24/96	Iwasaki et al.			

FOREIGN PATENT DOCUMENTS

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							YES	NO
JST		JP 6036929 A2 (Abstract only)	02/10/94	Japan				
JST		JP 4229607 A2 (Abstract only)	08/19/92	Japan				
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JST		Chen et al., "Soft-Magnetic Properties of Fe-Co-B Thin films For Ultra-High-Frequency Applications, J. App. Phys. 87, No. 9, 5858-5860(2000).
JST		Rehim et al. "Electroplating of CoFe Alloys From Aqueous Acetate Baths", Trans. IMF, 78, No. 1, 41-43(2000).

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John P. Sheehan

DATE CONSIDERED

9-7-2001

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Liu et al., "Electrodeposition of soft, high moment Co-Fe-Ni Thin Films", J. Appl. Phys., 87, No. 9, 5410-5412(2000).

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